



Editorial

# Acknowledgment to Reviewers of *Journal of Low Power Electronics and Applications* in 2020

*Journal of Low Power Electronics and Applications* Editorial Office

MDPI AG, St. Alban-Anlage 66, 4052 Basel, Switzerland

Peer review is the driving force of journal development, and reviewers are gatekeepers who ensure that *Journal of Low Power Electronics and Applications* maintains its standards for the high quality of its published papers. Thanks to the cooperation of our reviewers, in 2020, the median time to first decision was 18.8 days and the median time to publication was 2.9 days. The editors would like to express their sincere gratitude to the following reviewers for their precious time and dedication, regardless of whether the papers were finally published:

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